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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/663,948	09/16/2003	Rajesh Tiwari	TI-36211	3857	
23494	7590 11/28/2005	EXAMINER			
TEXAS INSTRUMENTS INCORPORATED P O BOX 655474, M/S 3999			CAO, PHAT X		
DALLAS, TX 75265			ART UNIT	PAPER NUMBER	
			2814		
			DATE MAILED: 11/28/2005		

Please find below and/or attached an Office communication concerning this application or proceeding.

Advisory Action Before the Filing of an Appeal Brief

Application No.	Applicant(s)		
10/663,948	TIWARI ET AL.		
Examiner	Art Unit		
Phat X. Cao	2814		

	Phat X. Cao	2814	
The MAILING DATE of this communication appe	ars on the cover sheet with the c	orrespondence add	ress
THE REPLY FILED <u>14 November 2005</u> FAILS TO PLACE THIS	S APPLICATION IN CONDITION F	OR ALLOWANCE.	
1. The reply was filed after a final rejection, but prior to or on this application, applicant must timely file one of the follow places the application in condition for allowance; (2) a No a Request for Continued Examination (RCE) in compliance time periods:	ving replies: (1) an amendment, aff tice of Appeal (with appeal fee) in (idavit, or other evider compliance with 37 C	nce, which FR 41.31; or (3)
a) The period for reply expires 3 months from the mailing date	of the final rejection.		
b) The period for reply expires on: (1) the mailing date of this A no event, however, will the statutory period for reply expire Is Examiner Note: If box 1 is checked, check either box (a) or (ater than SIX MONTHS from the mailin	g date of the final reject	ion.
TWO MONTHS OF THE FINAL REJECTION. See MPEP 70	06.07(f).		
Extensions of time may be obtained under 37 CFR 1.136(a). The date have been filed is the date for purposes of determining the period of extender 37 CFR 1.17(a) is calculated from: (1) the expiration date of the set forth in (b) above, if checked. Any reply received by the Office later may reduce any earned patent term adjustment. See 37 CFR 1.704(b)	tension and the corresponding amount shortened statutory period for reply origon than three months after the mailing da	of the fee. The approprinally set in the final Off	iate extension fee ce action; or (2) as
NOTICE OF APPEAL	liana with 27 OFD 44 27 much ha		fib data of
 The Notice of Appeal was filed on A brief in comp filing the Notice of Appeal (37 CFR 41.37(a)), or any exter a Notice of Appeal has been filed, any reply must be filed 	nsion thereof (37 CFR 41.37(e)), to	avoid dismissal of th	
AMENDMENTS The proposed emendment(s) filed after a final rejection.	but prior to the date of filing a brief	will not be entered b	ecause
3. The proposed amendment(s) filed after a final rejection, (a) They raise new issues that would require further co (b) They raise the issue of new matter (see NOTE below).	nsideration and/or search (see NO		ecause
(c) They are not deemed to place the application in bet appeal; and/or			the issues for
(d) They present additional claims without canceling a		ected claims.	
NOTE: (See 37 CFR 1.116 and 41.33(a)).		ampliant Amondment	(DTOL 324)
4. The amendments are not in compliance with 37 CFR 1.15		mphant Amendment	(F10L-324).
5. Applicant's reply has overcome the following rejection(s)6. Newly proposed or amended claim(s) would be al		timely filed amendme	ent canceling the
non-allowable claim(s).	nowable if submitted in a separate,	timely med amendim	
7. For purposes of appeal, the proposed amendment(s): a) how the new or amended claims would be rejected is pro- The status of the claim(s) is (or will be) as follows:		il be entered and an	explanation of
Claim(s) allowed:			
Claim(s) objected to: Claim(s) rejected: <u>1,2,4 and 9</u> .			
Claim(s) withdrawn from consideration: <u>5-8</u> .			
AFFIDAVIT OR OTHER EVIDENCE			
 The affidavit or other evidence filed after a final action, but because applicant failed to provide a showing of good an was not earlier presented. See 37 CFR 1.116(e). 	it before or on the date of filing a N d sufficient reasons why the affidate	otice of Appeal will <u>ne</u> vit or other evidence i	ot be entered s necessary and
9. The affidavit or other evidence filed after the date of filing entered because the affidavit or other evidence failed to of showing a good and sufficient reasons why it is necessar	overcome <u>all</u> rejections under appe	al and/or appellant fa	ils to provide a
10. The affidavit or other evidence is entered. An explanation REQUEST FOR RECONSIDERATION/OTHER	n of the status of the claims after e	ntry is below or attac	hed.
11. The request for reconsideration has been considered busee attached papers.	·		nce because:
12. ☐ Note the attached Information Disclosure Statement(s).13. ☐ Other:	(PTO/SB/08 or PTO-1449) Paper I	No(s)	

ADVISORY ACTION

1. Applicant argues that "The scraping of the shoulder portions is merely a result of the sputter and does not establish a minimum length from the trench edge and the via edge as required in claim 1."

This argument is not persuasive because Shimizu (Figs. 3H and 3I) clearly teaches the pad trench 12b (Fig. 3H) including a scraping portion and a planar portion (Fig. 3I) formed between the trench edge and the via edge. Therefore, the combination of the scraping portion and the planar portion of the pad trench 12b does establish a minimum length from the trench edge and the via edge.

2. Applicant further argues that the scraping off of the via edge to expand a diameter of the via does not participate in preventing the peeling-off of the plug.

This argument is not persuasive because of the following reasons:

- First, it is noted that when the structure recited in the reference is substantially identical to that of the claims, claimed properties or functions are presumed to be inherent. *In re Best*, 195 USPQ 430, 433 (CCPA 1977). In this case, as asserted by Applicant, the peeling-off of the plugs from the metal wirings results from the trench termination overhang Xto (see Applicant's Fig. 2C), the trench termination overhang Xto includes a first trench depth d1, a second trench depth d2 and a transition trench depth d3, where d2,d3,d1 (pages 7-8 of Applicant's specification). Similarly, Shimizu also discloses a copper interconnect structure having a trench termination overhang 12b (Fig. 3I), the trench termination overhang 12b includes a first trench depth

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d1, a second trench depth d2 and a transition trench depth d3 (corresponding to scrapoff portion between the edge of the via 12a and the edge of the trench 16). Therefore,
because the trench termination overhang of Applicant is not different from the trench
termination overhang of Shimizu, the trench termination overhang 12b of Shimizu would
have the same properties of preventing the peeling-off of the plugs from the metal
wirings.

- Second, it is further noted that once a reference teaching product appearing to be substantially identical is made the basis of a rejection and the examiner presents evidence or reasoning tending to show inherency, the burden shift to Applicant to show an unobvious difference. *In re Fitzgerall*, 205 USPQ 594 (CCPA 1980). In this case, Applicant fails to provide the reasons to support that why the trench termination overhang 12b of Shimizu would not have the same properties of preventing the peeling-off of the plugs from the metal wirings even though the trench termination overhang of Applicant is not different from the trench termination overhang of Shimizu.
- 3. Applicant also argues that Watanabe does not teach or suggest a minimum length between a via edge and a trench edge in a range as claimed.

This argument is not persuasive because of the following reasons:

- First, Watanabe (Figs. 24b-24c) clearly teaches a forming of a copper interconnect structure comprising a trench 603 formed over a plurality of vias 602, the trench 603 extends a length of 0.4 um beyond the edge of the via 602 closest to the first edge of the trench (par. [0175]). Specifically, Watanabe discloses that "16 via patterns" 602 can be formed per one wiring pattern". "In this example, it is assumed that the

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width W of the wiring patterns ... 603 is 10 um, and pitch P of the via patterns 602 is 0.6 um." Accordingly, the total pitch P of the 16 via patterns would be equal 9.6 um (16 via \times 0.6 um), and the length between a via edge and a trench edge would be equal the different between the width W of the wiring pattern 603 (i.e., 10 um) and the total pitch P of the 16 via patterns (i.e., 9.6 um) or equal 0.4 um (10 um – 9.6 um). Therefore, Watanabe does teach a minimum length between a via edge and a trench edge in a range as claimed.

- Second, there is nothing in the Applicant specification, which supports that the peeling-off of the plugs from the metal wirings will not result for the trench extension overhang less than 0. 2 um beyond the edge of a via. It appears that the peeling-off of the plugs from the metal wirings would be prevented for any lengths of the trench extension overhang. It should be noted that "the law is replete with cases in which the difference between the claimed invention and the prior art is some range or other variable within the claims ... In such a situation, the Applicant must show that the particular range is critical, generally by showing that the claimed range achieves unexpected results relative to the prior art range." *In re Woodruff*, 919 F. 2d 1575, 16 USPQ 2d 1934 (Fed. Cir. 1990).
- 4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Phat X. Cao whose telephone number is 571-272-1703. The examiner can normally be reached on M-F.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Wael Fahmy can be reached on 571-272-1705. The fax phone number for

the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the

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Business Center (EBC) at 866-217-9197 (toll-free).

PC

November 22, 2005

PHAT X. CAO
PRIMARY EXAMINER

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